

REMARKS

Claims 1, 2 and 4 are pending in this application. By this Amendment, claims 5-6, 8-15 and 17 are canceled and the specification is amended. Reconsideration of the present application based on the above amendments and the following remarks is respectfully requested.

Applicant thanks the Examiner for the courtesies extended to Applicant's representative during the personal interview held December 2, 2004. Applicant's separate record of the substance of the personal interview is incorporated into the following remarks.

During the personal interview, distinguishing features of claim 1 with respect to U.S. Patent 6,025,607 to Ohori, U.S. Patent 6,078,060 to Shibuya and U.S. Patent Application Publication No. 2002/0068372 to Kunii were discussed. The points presented included the arguments found in the Amendment filed October 28, 2004. Specifically, Applicant's representative asserted that none of the applied art disclose individually, or in combination, a thin-film transistor, comprising an active region, a source region, and a drain region, an area of a cross section of the source region being approximately equal to an area of a cross section of the drain region, the lightly doped impurity regions being provided in an asymmetrical form in which the lightly doped impurity region in the source region is smaller than the drain region, as claimed in claim 1. The Examiner agreed that the applied art does not disclose all of the features of claim 1.

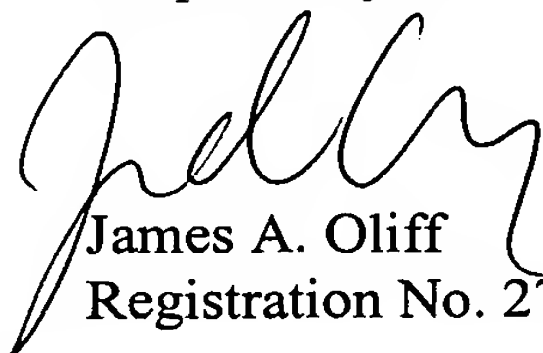
The Examiner requested the features recited in claim 1, "an area of a cross section of the source region being approximately equal to an area of a cross section of the drain region, said cross sections taken along a plane generally perpendicular to a mounting surface of the thin-film transistor," be incorporated into the specification. The Examiner agreed that all of these features are clearly shown and supported by at least in Fig. 4 as originally filed. As such, the Amendment amends the specification as recited by the Examiner.

Because the Examiner agreed during the personal interview that the applied art does not disclose all of the features of claim 1, it is respectfully submitted that claim 1 is distinguishable over the applied art. Furthermore, those claims which depend from claim 1 are likewise distinguishable over the applied art for at least the reasons discussed above, as well as for additional features they recite. Accordingly, withdrawal of the rejections is respectfully requested.

In view of the foregoing, it is respectfully submitted that this application is in condition for allowance. Favorable reconsideration and prompt allowance of claims 1, 2 and 4 are earnestly solicited.

Should the Examiner believe that anything further would be desirable in order to place this application in even better condition for allowance, the Examiner is invited to contact the undersigned at the telephone number set forth below.

Respectfully submitted,


James A. Oliff
Registration No. 27,075

Jude L. Cooney
Registration No. 54,045

JAO:JLC/aaw

Date: **December 10, 2004**

OLIFF & BERRIDGE, PLC
P.O. Box 19928
Alexandria, Virginia 22320
Telephone: (703) 836-6400

<p>DEPOSIT ACCOUNT USE AUTHORIZATION Please grant any extension necessary for entry; Charge any fee due to our Deposit Account No. 15-0461</p>
--